

Notice of References Cited

Application/Control No.

09/176,422

Examiner

Neal Berezny

Applicant(s)/Patent Under
Reexamination
Wilk et al.

Art Unit

2823

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U.S. PATENT DOCUMENTS

*		DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	DOCUMENT SOURCE **	
							APS	OTHER
<input type="checkbox"/>	A	5,294,571	Mar. 1994	Fujishiro et al.	437	239	<input checked="" type="checkbox"/>	<input type="checkbox"/>
<input type="checkbox"/>	B	5,275,687	Jan. 1994	Choquette et al.	156	612	<input checked="" type="checkbox"/>	<input type="checkbox"/>
<input type="checkbox"/>	C	5,194,397	Mar. 1993	Cook et al.	437	31	<input checked="" type="checkbox"/>	<input type="checkbox"/>
<input type="checkbox"/>	D	4,604,304	Aug. 1986	Faraone et al.	427	255	<input checked="" type="checkbox"/>	<input type="checkbox"/>
<input type="checkbox"/>	E	4,851,370	Jul. 1989	Doklan et al.	437	225	<input checked="" type="checkbox"/>	<input type="checkbox"/>
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FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

*		DOCUMENT (Including Author, Title Date, Source, and Pertinent Pages)	DOCUMENT SOURCE **	
			APS	OTHER
<input type="checkbox"/>	U	Nayar, V.; Patel, P.; Boyd, I. W.; "Atmospheric pressure, low temperature (<500 C) UV/ozone oxidation of silicon," Electron. Lett., vol.26, pp. 205-206, 1990.	<input type="checkbox"/>	<input checked="" type="checkbox"/>
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*A copy of this reference is not being furnished with this Office action. (See Manual of Patent Examining Procedure, Section 707.05(a).)

**APS encompasses any electronic search i.e. text, image, and Commercial Databases.

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